Electronic Acknowledgement Receipt					
EFS ID:	1224377				
Application Number:	09700236				
Confirmation Number:	3694				
Title of Invention:	Crystal growth method for group-III nitride and related compound semiconductors				
First Named Inventor:	Xiong Zhang				
Correspondence Address:	David H Jaffer Pillsbury Winthrop 2550 Hanover Street - Palo Alto CA 94304-4040 US 6502334545				
Filer:	David Hussain Jaffer/Diana Dearing				
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Application Type:	U.S. National Stage under 35 USC 371				
International Application Number:					

## Payment information:

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## File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part	Pages			
1	Change of Address	614720269224_2.PDF	15374	no	1			
Warnings:					1			
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	Total Files Size (in bytes): 15374							

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## New Applications Under 35 U.S.C. 111

If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

## National Stage of an International Application under 35 U.S.C. 371

If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.